



Modelling & Simulation

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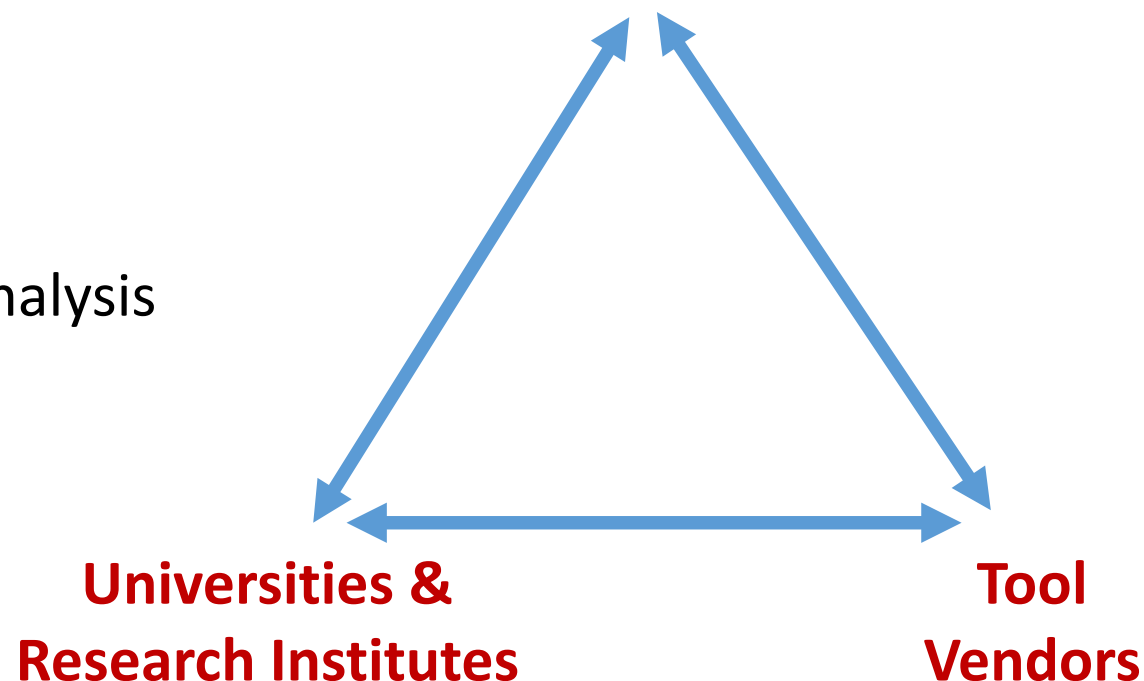
Co-Chairs



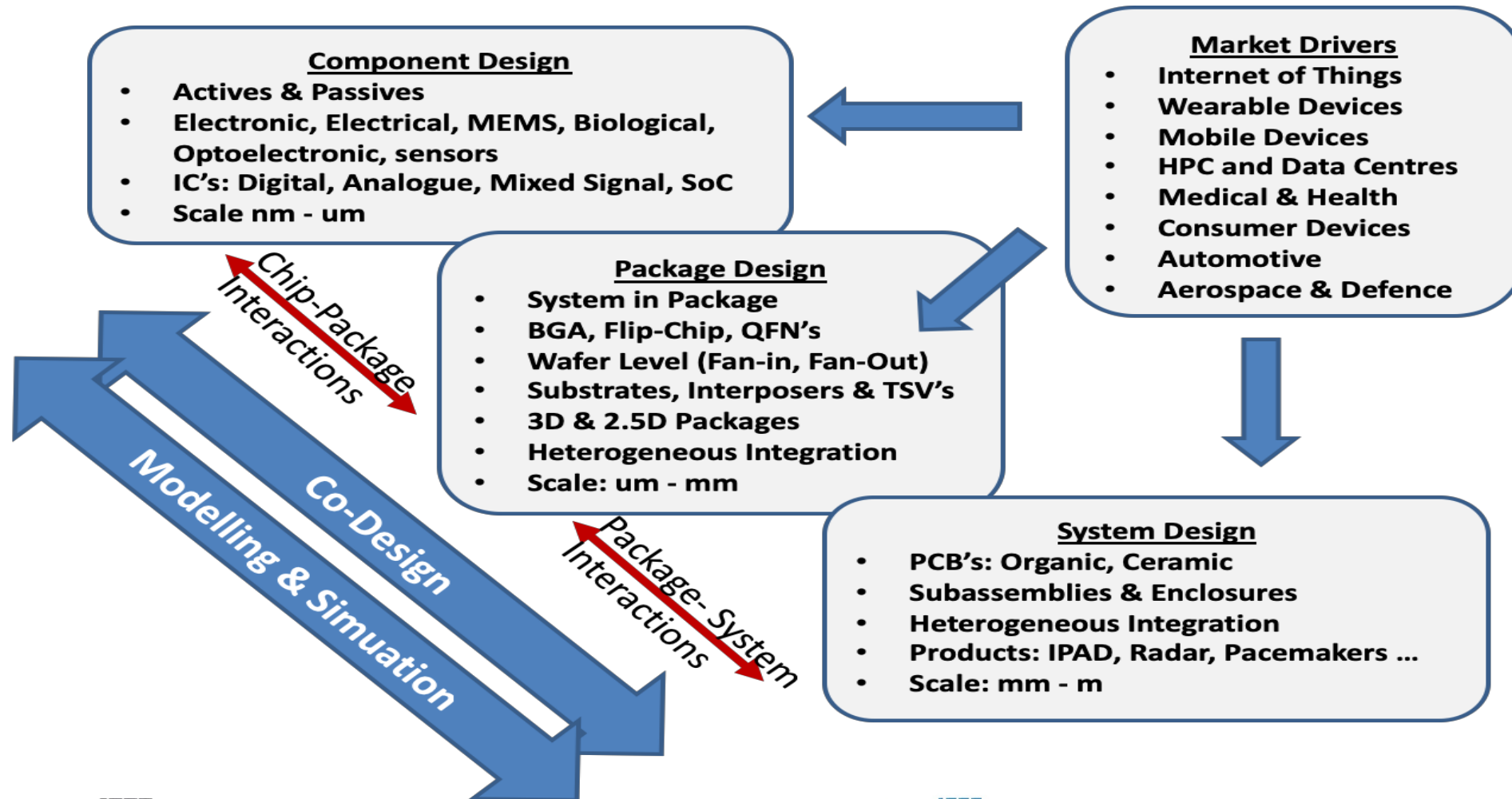
Scope

- Key Stakeholders
- Five sections
 - Electrical Analysis
 - Thermal Analysis
 - Materials Modelling
 - Mechanical & Multi-Physics Analysis
 - Reliability and Prognostics
- Chapter details
 - State of the Art
 - Challenges/Requirements
 - Potential solutions

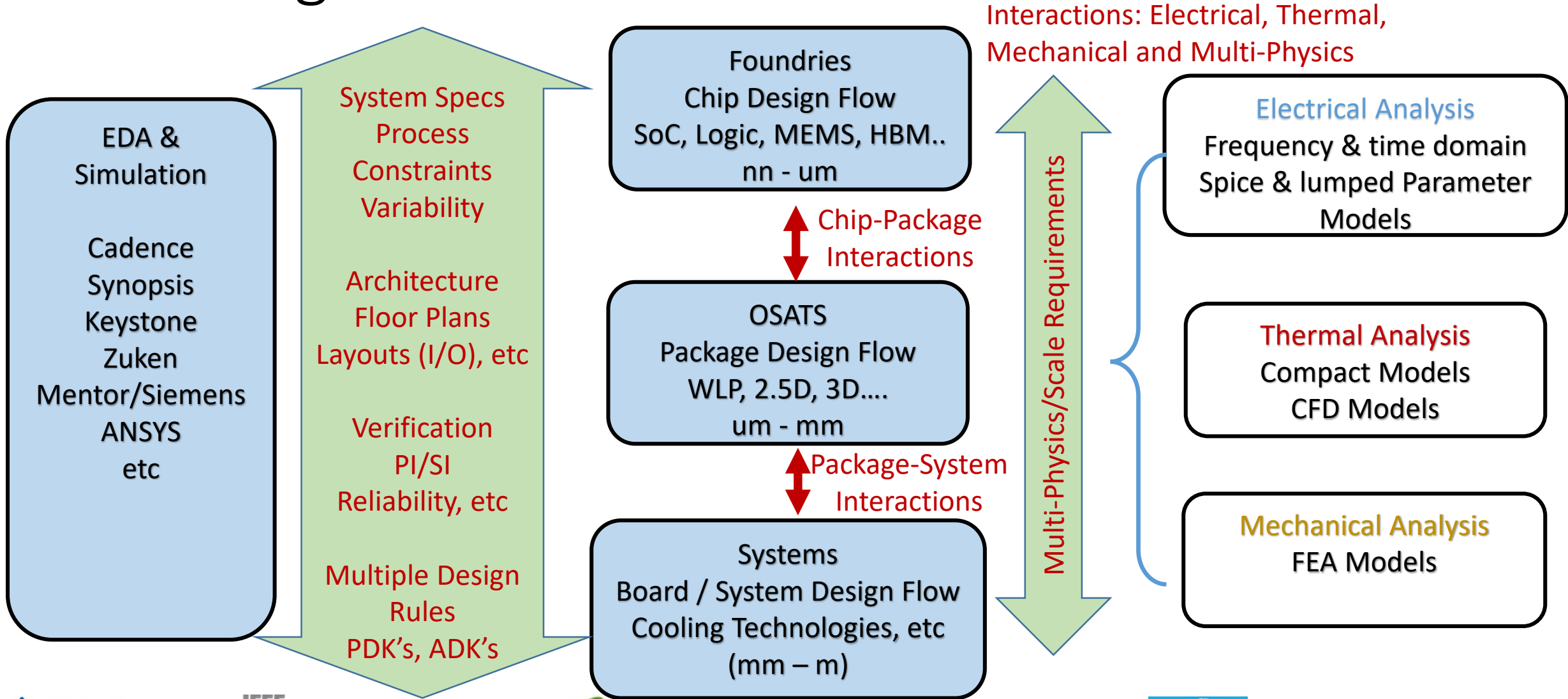
**Industry and Designers of
Heterogeneous Integrated System**



Supporting the Knowledge Base for HI



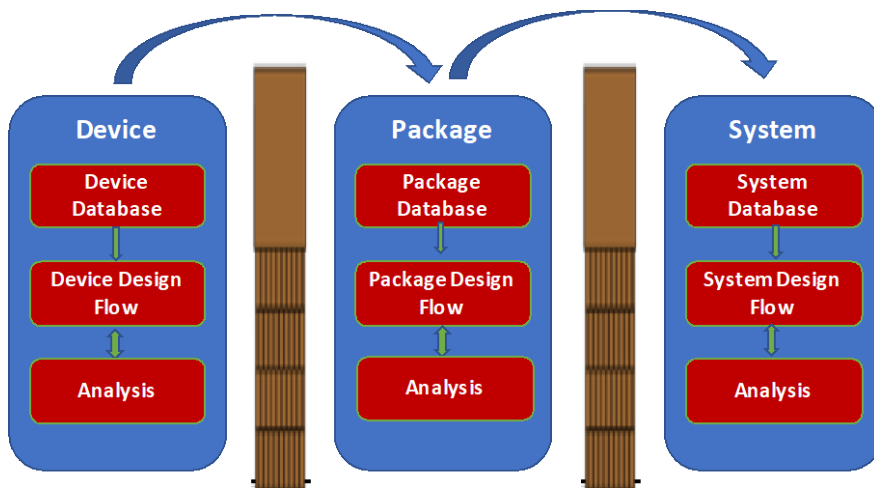
HI Design and Simulation Environment



Moving towards a new Paradigm

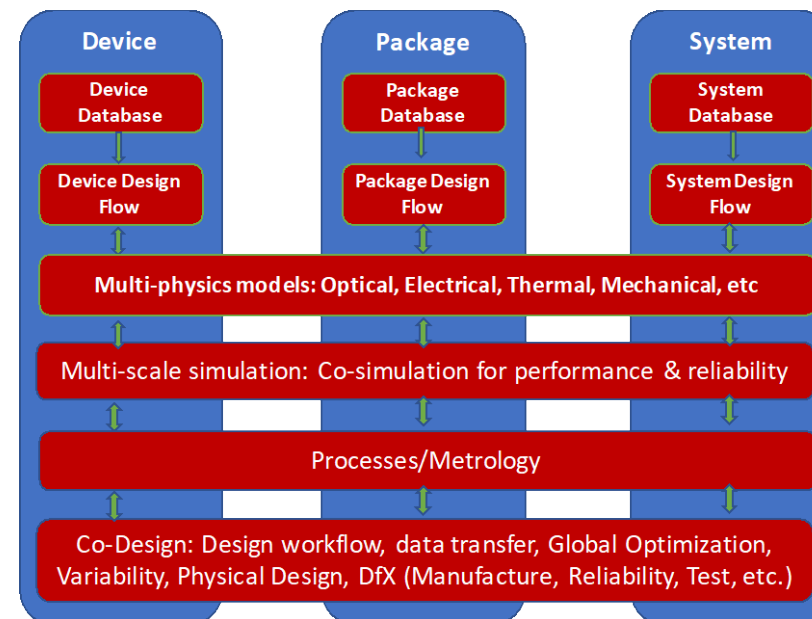


Today (Generally)



- Different design flows / Tools
- EDA (Spice Models, PDK's)
- Packaging (ADK's);Therma/Mechanical – System level

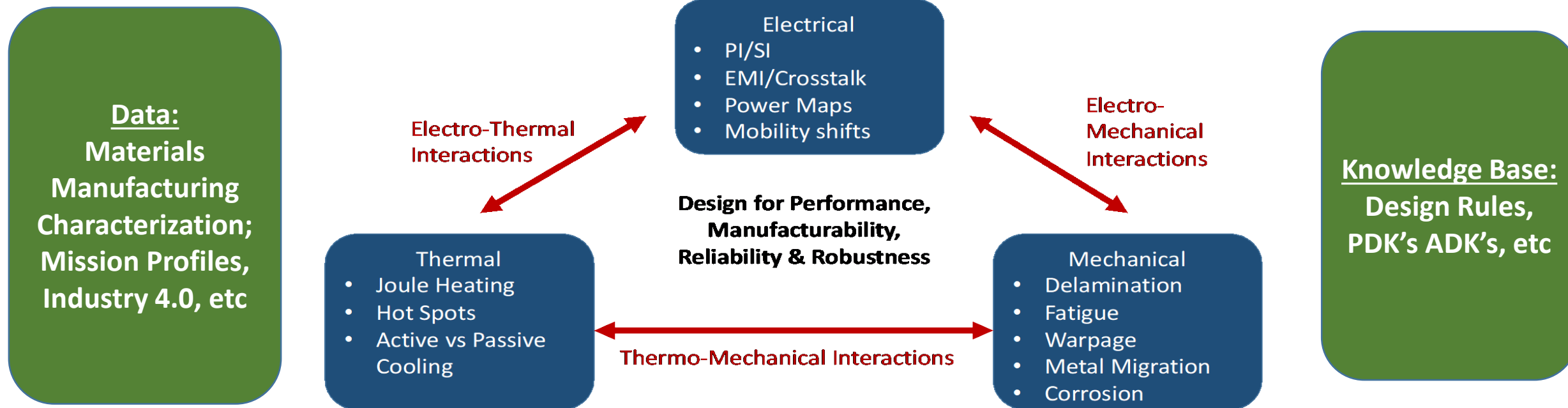
Future



- Design flow that captures Multi-Physics/Scale Interactions
- Collaborative Design
- System aware design

Multi-Physics/Scale Domains

Scale: Devices (nm) Packages(um-mm) Boards (mm-cm) Systems (cm-m)

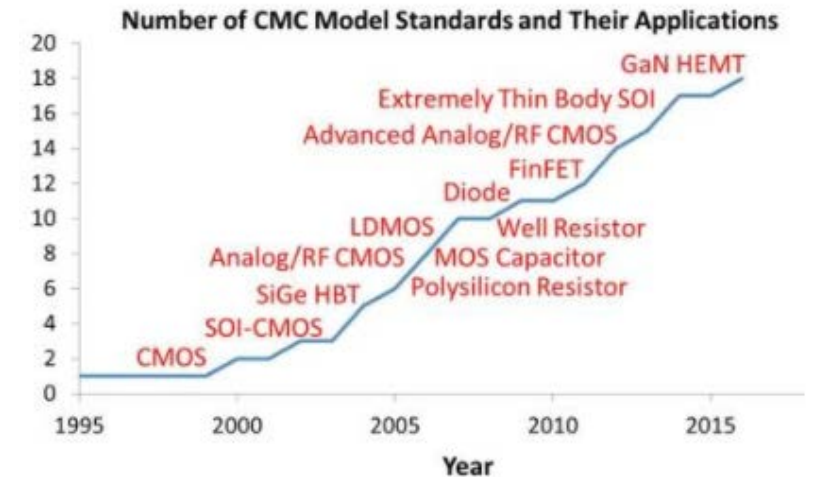
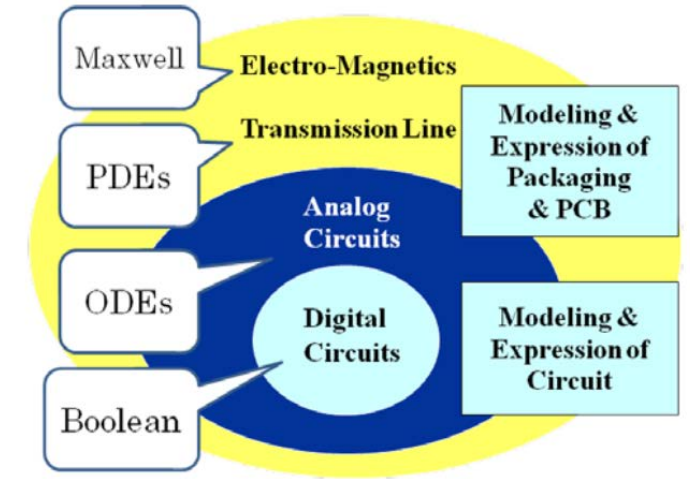


Model Fidelity: Analytical Circuit/Network Compact/Response Surface MOR MD/FEA/CFD

Model based Optimization; Big Data Analytics; Physics of Failure Models; Prognostics; etc.

Electrical Analysis

- State of the art
 - Solvers: SPICE, IBIS, MoMaxwell Solvers (FDTD), etc.
 - Customised solutions for die, package and system
- Challenges/Requirements
 - Accurate simulations for scale of features (die <-> package <-> System)
 - Standardisation of interface files between tools
- Potential Solutions
 - Compact models for co-analysis
 - Integrated solutions for Power and Signal Integrity / EMC, etc
 - Application of machine learning for generating fast models for use in HI EDA design flows



The CMC has been developing modeling standards for nearly two decades.

Thermal Analysis

- State of the art

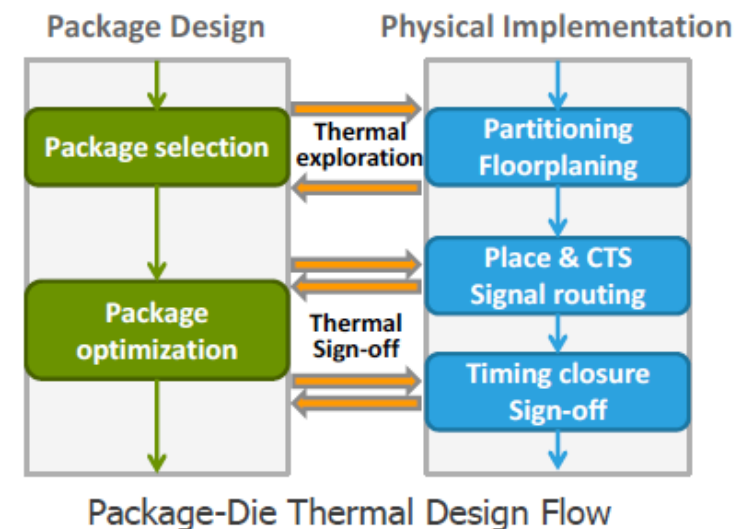
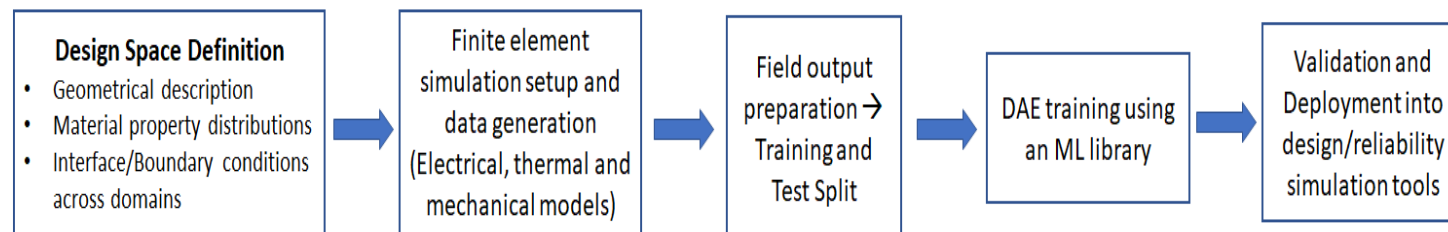
- CFD/FEM: Complex set-up

- Challenges/Requirements

- Self heating - Localised hot-spots
- Ability to predict temperatures across the length scales
- Accurate models for active cooling

- Potential Solutions

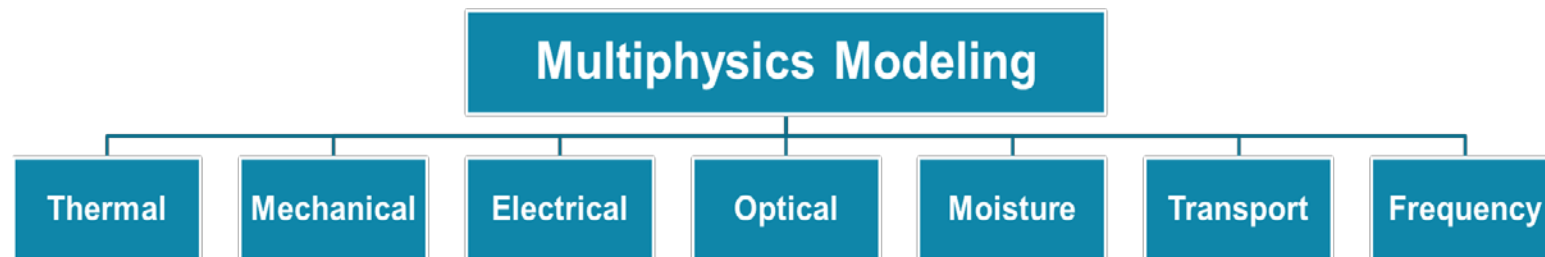
- Probabilistic input parameters to CFD
- Use CFD models for machine learning training for deep autoencoders (DAE)
- Use DAE in HI EDA design flows



DAC Designer Track 2017 | *Pascal Vivet*

Mechanical & Multi-Physics

- State of the art
 - Finite Element tools
 - Compute intensive tools



- Challenges/Requirements
 - Stress in die due to package constraints
 - Stochastic Models for Materials
 - Multi-physics aware floor-planning/placement

- Potential Solutions
 - Fast accurate ROM models for stress/warpage
 - Combined physics models with machine learning
 - Integrate into HI EDA design flow

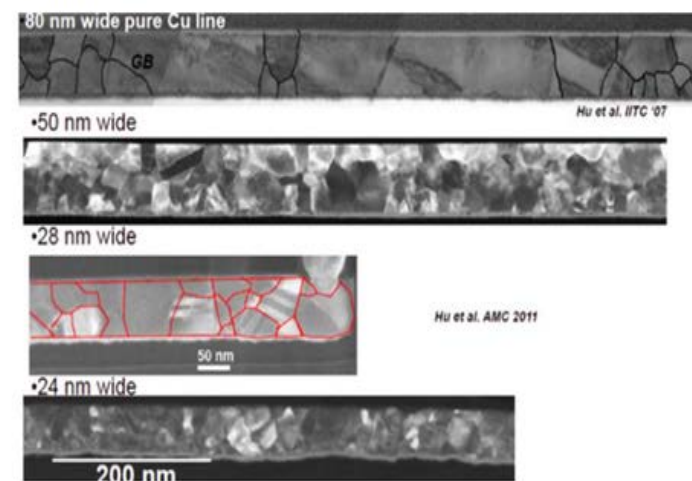
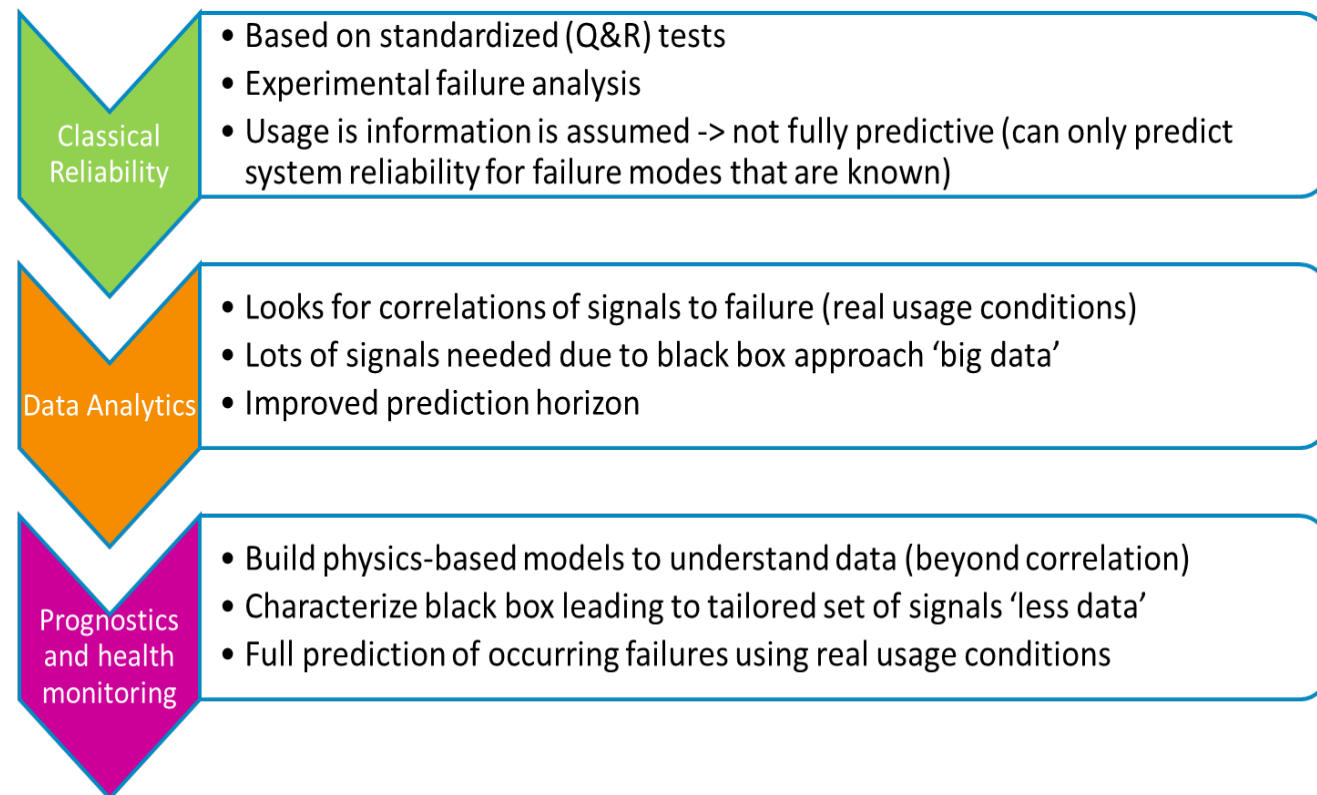


Fig. 7 Copper metal line scaling over the past generations of CMOS technology

Reliability & Prognostics

- State of the art
 - Classical reliability
 - Physics of failure (PoF) models
- Challenges/Requirements
 - New failure mechanisms/modes
 - System health management
 - Smart Testing
- Potential Solutions
 - New PoF models
 - Prognostics (Data and model driven)
 - Combined physics models with machine learning for integration into HI EDA design flows



Metrics

| Metric | 5 years | 10 years | 15 years |
|--|---|--|---|
| Concept to Product | 5 years | 3 years | 18 months |
| DfR (Accuracy) | 200% | 150% | 110% |
| Product validation in Virtual Environment | 50% | 70% | 100% |
| AI/Machine Learning | Use of Machine Learning - - single package and physics | Use of Machine Learning - multiple packages and single physics | Use of Machine Learning - for multiple packages and physics |
| Multi-Physics | Electro-thermal analysis at single package level (chip-package co-design) | Accurate multi-physics analysis for chip-package co-design | Accurate multi-physics analysis for whole system |
| Data Sharing | Interfaces between tools and ADK's and PDK's | Data and model sharing through supply chain | |

Acknowledgements and Status

- TWG Members & Contributors

- Chris Bailey (University of Greenwich)
- Dale Becker (IBM)
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- Robert Rao (Microchip)
- Abhijit Dasgupta (Univ Maryland)

- Status

- Version 1 complete
- Editing taken place
- Some minor additions expected
 - Reliability section
 - Metrics
- Ready for peer review
- Version 2
 - Closer alignment with Co-Design Chapter
 - Optical analysis
 - Materials Characterisation for models